

2. BASIC CRYSTALLOGRAPHY

where \mathbf{S} is a vector perpendicular to the plane reflecting the incident beam at an angle θ ; the length of \mathbf{S} is given by $|\mathbf{S}| = 2 \sin \theta / \lambda$ [equation (2.1.4.3) in Section 2.1.4.2].

The origin of the system is chosen at the origin of the selected unit cell. Atom j is at position \mathbf{r}_j with respect to the origin. Another unit cell has its origin at $t \times \mathbf{a}$, $u \times \mathbf{b}$ and $v \times \mathbf{c}$, where t , u and v are whole numbers, and \mathbf{a} , \mathbf{b} and \mathbf{c} are the basis vectors of the unit cell. With respect to the first origin, its scattering is

$$F(\mathbf{S}) \exp(2\pi i t \mathbf{a} \cdot \mathbf{S}) \exp(2\pi i u \mathbf{b} \cdot \mathbf{S}) \exp(2\pi i v \mathbf{c} \cdot \mathbf{S}).$$

The wave scattered by a crystal is the sum of the waves scattered by all unit cells. Assuming that the crystal has a very large number of unit cells ($n_1 \times n_2 \times n_3$), the amplitude of the wave scattered by the crystal is

$$W_{\text{cr}}(\mathbf{S}) = F(\mathbf{S}) \sum_{t=0}^{n_1} \exp(2\pi i t \mathbf{a} \cdot \mathbf{S}) \sum_{u=0}^{n_2} \exp(2\pi i u \mathbf{b} \cdot \mathbf{S}) \times \sum_{v=0}^{n_3} \exp(2\pi i v \mathbf{c} \cdot \mathbf{S}). \quad (2.1.4.6)$$

For an infinitely large crystal, the three summations over the exponential functions are delta functions. They have the property that they are zero unless

$$\mathbf{a} \cdot \mathbf{S} = h, \quad \mathbf{b} \cdot \mathbf{S} = k \quad \text{and} \quad \mathbf{c} \cdot \mathbf{S} = l, \quad (2.1.4.7)$$

where h , k and l are whole numbers, either positive, negative or zero. These are the Laue conditions. If they are fulfilled, all unit cells scatter in phase and the amplitude of the wave scattered by the crystal is proportional to the amplitude of the structure factor F . Its intensity is proportional to $|F|^2$.

\mathbf{S} vectors satisfying equation (2.1.4.7) are denoted by $\mathbf{S}(hkl)$ or $\mathbf{S}(\mathbf{h})$, and the corresponding structure factors as $F(hkl)$ or $F(\mathbf{h})$.

Bragg's law for scattering by a crystal is better known than the Laue conditions:

$$2d \sin \theta = \lambda, \quad (2.1.4.8)$$

where d is the distance between reflecting lattice planes, θ is the reflecting or glancing angle and λ is the wavelength (Fig. 2.1.4.9). It can easily be shown that the Laue conditions and Bragg's law are equivalent by combining equation (2.1.4.7) with the following information:

- (1) Vector \mathbf{S} is perpendicular to a reflecting plane (Section 2.1.4.2).
- (2) The Laue conditions for scattering [equation (2.1.4.7)] can be written as

$$\frac{\mathbf{a}}{h} \cdot \mathbf{S} = 1; \quad \frac{\mathbf{b}}{k} \cdot \mathbf{S} = 1; \quad \frac{\mathbf{c}}{l} \cdot \mathbf{S} = 1. \quad (2.1.4.9)$$

- (3) Lattice planes always divide the unit-cell vectors \mathbf{a} , \mathbf{b} and \mathbf{c} into a number of equal parts (Section 2.1.1). If the lattice planes divide the \mathbf{a} vector of the unit cell into h equal parts, the first index for this set of planes is h . The second index, k , is related to the division of \mathbf{b} and the third index, l , to the division of \mathbf{c} .

From equation (2.1.4.9) it follows that vector $\mathbf{S}(hkl)$ is perpendicular to a plane determined by the points \mathbf{a}/h , \mathbf{b}/k and \mathbf{c}/l , and according to conditions (3) this is a lattice plane. Therefore, scattering by a crystal can indeed be regarded as reflection by lattice planes. The projection of \mathbf{a}/h , \mathbf{b}/k and \mathbf{c}/l on vector $\mathbf{S}(hkl)$ is $1/|\mathbf{S}(hkl)|$ (Laue condition), but it is also equal to the spacing $d(hkl)$ between the lattice planes (see Fig. 2.1.1.3), and, therefore,

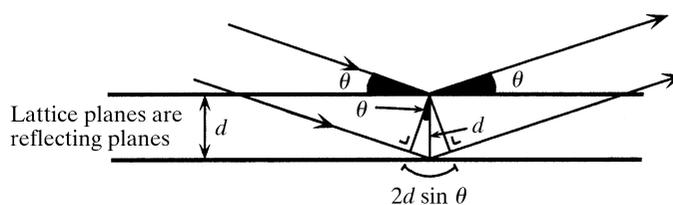


Figure 2.1.4.9

X-ray diffraction by a crystal is, in Bragg's conception, reflection by lattice planes. The beams reflected by successive planes have a path difference of $2d \sin \theta$, where d is the lattice-plane distance and θ is the reflecting angle. Positive interference occurs if $2d \sin \theta = \lambda$, 2λ , 3λ etc., where λ is the X-ray wavelength. Reproduced with permission from Drenth (1999). Copyright (1999) Springer-Verlag.

$|\mathbf{S}(hkl)| = 1/d(hkl)$. Combining this with equation (2.1.4.3) yields Bragg's law, $2d \sin \theta = \lambda$ [equation (2.1.4.8)].

2.1.4.6. The structure factor

For noncentrosymmetric structures, the structure factor,

$$F(\mathbf{S}) = \sum_{j=1}^n f_j \exp(2\pi i \mathbf{r}_j \cdot \mathbf{S}),$$

is an imaginary quantity and can also be written as²

$$F(\mathbf{S}) = \sum_{j=1}^n f_j \cos(2\pi \mathbf{r}_j \cdot \mathbf{S}) + i \sum_{j=1}^n f_j \sin(2\pi \mathbf{r}_j \cdot \mathbf{S}) = A(\mathbf{S}) + iB(\mathbf{S}).$$

It is sometimes convenient to split the structure factor into its real part, $A(\mathbf{S})$, and its imaginary part, $B(\mathbf{S})$. For centrosymmetric structures, $B(\mathbf{S}) = 0$ if the origin of the structure is chosen at the centre of symmetry.

The average value of the structure-factor amplitude $|F(\mathbf{S})|$ decreases with increasing $|\mathbf{S}|$ or, because $|\mathbf{S}| = 2 \sin \theta / \lambda$, with increasing reflecting angle θ .

This is caused by two factors:

- (1) A stronger negative interference between the electrons in the atoms at a larger scattering angle; this is expressed in the decrease of the atomic scattering factor as a function of \mathbf{S} .
- (2) The temperature-dependent vibrations of the atoms. Because of these vibrations, the apparent size of an atom is larger during an X-ray exposure, and the decrease in its scattering as a function of \mathbf{S} is stronger. If the vibration is equally strong in all directions, it is called isotropic, and the atomic scattering factor must be multiplied by a correction factor, the temperature factor, $\exp[-B(\sin^2 \theta) / \lambda^2]$. It can be shown that the parameter B is related to the mean-square displacement of the atomic vibrations, $\overline{u^2}$:

$$B = 8\pi^2 \overline{u^2}.$$

In protein crystal structures determined at high resolution, each atom is given its own individual thermal parameter B .³ Anisotropic thermal vibration is described by six parameters instead of one, and the evaluation of this anisotropic thermal vibration requires more data (X-ray intensities) than are usually available. Only at very high resolution (better than 1.5 Å) can one consider the incorporation of anisotropic temperature factors.

² For convenience, we write $F(\mathbf{S})$ when we mean $F(hkl)$ or $F(\mathbf{h})$, and \mathbf{S} instead of $\mathbf{S}(hkl)$ or $\mathbf{S}(\mathbf{h})$.

³ Do not confuse the thermal parameter B with the imaginary part $B(\mathbf{S})$ of the structure factor.